# AOS Semiconductor Product Reliability Report 

## AOZ5311NQI rev.1.

Plastic Encapsulated Device

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This AOS product reliability report summarizes the qualification results for AOZ5311NQI in QFN5x5-31L package.

Review of the electrical test results confirmed that AOZ5311NQI passes AOS quality and reliability requirements for final product and package release.

## I. Table of Contents:

## General Description:

AOZ5311NQI is a high-efficiency synchronous buck power stage module consisting of two asymmetrical MOSFETs and an integrated driver. AOZ5311NQI is available in a tiny $5 \mathrm{~mm} \times 5 \mathrm{~mm} 31$-pin QFN package and is rated over a $-40^{\circ} \mathrm{C}$ to $+125^{\circ} \mathrm{C}$ operating temperature range.

| Absolute Maximum Ratings |  |
| :--- | :--- |
| Parameter | -0.3 V to 7 V |
| Low Voltage Supply <br> VCC, PVCC | -0.3 V to 25 V |
| High Voltage Supply <br> VIN | -0.3 V to (VCC+0.3V) |
| Control Inputs <br> PWM, FCCM | -0.3 V to 32 V |
| Bootstrap Voltage DC <br> (BOOT - PGND) | -0.3 V to 7 V |
| Bootstrap Voltage DC <br> (BOOT - VSWH) | -0.3 V to 9 V |
| Bootstrap Voltage Transient (1) <br> (BOOT - VSWH) | -0.3 V to 25 V |
| Switching Node Voltage DC <br> VSWH | -8 V to 33 V |
| Switching Node Voltage Transient (2) <br> VSWH | (PGND-0.3V) to (PVCC+0.3V) |
| Low Side Gate Voltage DC <br> GL | (PGND-2.5V) to (PVCC+0.3V) |
| Low Side Gate Voltage Transient (2) <br> GL | $-65^{\circ} \mathrm{C}$ to $150^{\circ} \mathrm{C}$ |
| Storage Temperature <br> (Ts) | $150^{\circ} \mathrm{C}$ |
| Max Junction Temperature <br> (Tj) | 2 kV |
| ESD Rating (3) | 4.5 V to 20 V |
| Recommended Operating Ratings |  |
| High Voltage Supply <br> VIN, VSWH | 4.5 V to 5.5 V |
| Low Voltage Supply, Logic <br> VCC, PVCC |  |

Note:
(1) Peak voltages can be applied for 10 ns per switching cycle
(2) Peak voltages can be applied for 20 ns per switching cycle
(3) Devices are inherently ESD sensitive. Handling precautions are required. Human Body Model rating: $1.5 \mathrm{k} \Omega$ in series with 100 pF

## II. Package and Die Information:

| Product ID | AOZ5311NQI |
| :---: | :---: |
| Package Type | QFN5x5-31L |
| Die Size | IC: $960 \times 1040 \mathrm{um} 2$ <br> HS MOSFET: $1150 \times 1820 \mathrm{um} 2$ <br> LS MOSFET: $1800 \times 2250 \mathrm{um} 2$ |
| Die attach material | IC: non-conductive epoxy MOSFETs: solder paste |
| Bond wire | Au, 1.0 mil |
| Mold Material | EME-G700HC D14*5.8g |
| Lead Plating | Pure Sn |
| MSL | Level 1 |

## III. Qualification Tests Requirements

o AOZ5311NQI is a derivative product
o 3 lots 1000 hrs HTOL
o 3 lots preconditioning, 96 hr PCT, 96 hr uHAST, 1000 cycle TC, 1000 hr HTS
o 1 lot HBM, CDM ESD, Latchup
o 2 lots 1000 hr HTRB, HTGB (MOSFETs, derivative qualification)
o $3 x$ IR reflow +250 cycle TC

## IV. Qualification Tests Result

| Test Item | Test Condition | Sample Size | Result | Comment |
| :---: | :---: | :---: | :---: | :---: |
| HTOL | $\begin{aligned} & \text { Per JESD 22-A108B } \\ & \mathbf{V}_{\text {IN }}=25 \mathrm{~V} \\ & \mathrm{~T}_{\mathrm{J}}=150^{\circ} \mathrm{C} \\ & \hline \end{aligned}$ | 3 lots (80/lot) | pass 1000hrs |  |
| ESD | $\begin{aligned} & \text { JESD 22-A114E (HBM) } \\ & \text { JESD 22-A115A (MM) } \\ & \text { JESD 22-C101C (CDM) } \end{aligned}$ | 3 units | pass | $\begin{aligned} & \text { 2.0kV (HBM) } \\ & \text { 200V (MM) } \\ & 1.0 \mathrm{kV} \text { (CDM) } \end{aligned}$ |
| Latch-up | Per JESD 78A | 6 units | pass | $\pm 100 \mathrm{~mA}$ |
| Power Cycling | $\begin{aligned} & \mathrm{V}_{\text {IN }}=19 \mathrm{~V}, \mathrm{~V}_{\text {OUT }}=1.0 \mathrm{~V}, \mathrm{~F}_{\text {SW }}=800 \mathrm{kHz}, \\ & \mathrm{I}_{\text {OUT }}=30 \mathrm{~A}, \text { VCC cycled } 0 \mathrm{~V}-5 \mathrm{~V} \end{aligned}$ | 10 units | pass | $\begin{aligned} & \hline \text { 35hr, } \\ & >63 \mathrm{k} \text { cycles } \end{aligned}$ |
| $\begin{aligned} & \text { HTGB } \\ & \text { (MOSFETs) } \end{aligned}$ | $\begin{aligned} & \text { Temp }=150^{\circ} \mathrm{C} \\ & \mathrm{~V}_{\mathrm{GS}}=12 \mathrm{~V} \end{aligned}$ | $\begin{aligned} & 1 \text { lot HS MOSFET ( } 77 \mathrm{pcs} \text { ) } \\ & 1 \text { lot LS MOSFET ( } 77 \mathrm{pcs} \text { ) } \\ & 9 \text { lots MOSFET ( } 77 / \mathrm{lot} \text { ) } \end{aligned}$ | pass 1000hrs pass 1000hrs pass 1000hrs | Derivative process Derivative process Platform process |
| HTRB (MOSFETs) | $\begin{aligned} & \text { Temp }=150^{\circ} \mathrm{C} \\ & V_{\text {DS }}=25 \mathrm{~V} \end{aligned}$ | $\begin{aligned} & 1 \text { lot HS MOSFET ( } 77 \mathrm{pcs} \text { ) } \\ & 1 \text { lot LS MOSFET ( } 77 \mathrm{pcs} \text { ) } \\ & 9 \text { lots MOSFET ( } 77 / \mathrm{lot} \text { ) } \end{aligned}$ | pass 1000hrs pass 1000hrs pass 1000hrs | Derivative process Derivative process Platform process |
| $\begin{aligned} & \text { H3TRB } \\ & \text { (MOSFETs) } \end{aligned}$ | $\mathrm{T}_{\mathrm{A}}=85^{\circ} \mathrm{C}, \mathbf{8 5 \%} \mathrm{RH}, \mathrm{V}_{\text {DS }}=\mathbf{2 5 V}$ | 3 lots (77/lot) | Pass 1000hr | Platform process |
| $\begin{aligned} & \text { HAST } \\ & \text { (MOSFETs) } \end{aligned}$ | $130^{\circ} \mathrm{C}+/-2^{\circ} \mathrm{C}, \mathbf{8 5 \%}$ RH, 33.3 psi | 3 lots (77/lot) | pass 96hrs | Platform process |
| Power Cycling (MOSFETs) | $\mathrm{T}_{\mathrm{A}}=25^{\circ} \mathrm{C}, \mathrm{T}_{\mathrm{J}}=125^{\circ} \mathrm{C}$ | 3 lots (77/lot) | pass 15k cycles | Platform process |

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| Test Item | Test Condition | Sample Size | Result | Comment |
| :---: | :---: | :---: | :---: | :---: |
| $3 x$ IR reflow and 250 Temperature Cycles | 3x IR reflow @ $260^{\circ} \mathrm{C}$; TC test condition: $-65^{\circ} \mathrm{C}$ to $+150^{\circ} \mathrm{C}$, air to air (2cyc/hr) | 3 lots (3000 /lot) | pass |  |
| Pre-Conditioning (MSL1) | Per JESD 22-A113 $85^{\circ} \mathrm{C}, 85 \% \mathrm{RH}, 3$ cycle reflow @ $260^{\circ} \mathrm{C}$ | 3 lots (308/lot) | pass MSL1 |  |
| PCT | $\begin{aligned} & 121^{\circ} \mathrm{C}, 15 \pm 1 \mathrm{PSI}, \\ & \text { RH }=100 \% \end{aligned}$ | 3 lots (77/lot) | pass 96hrs |  |
| UHAST | $\begin{aligned} & 130+/-2^{\circ} \mathrm{C}, 85 \% \mathrm{RH}, 33.3 \\ & \mathrm{psi} \end{aligned}$ | 3 lots (77/lot) | pass 96hrs |  |
| Temperature Cycle | $-65^{\circ} \mathrm{C}$ to $+150^{\circ} \mathrm{C}$, air to air (2cyc/hr) | 3 lots (77/lot) | pass 1000 cycles |  |
| HTS | $\mathrm{T}_{\mathrm{A}}=+150^{\circ} \mathrm{C}$ | 3 lots (77/lot) | pass 1000hrs |  |

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## V. Reliability Evaluation

The presentation of FIT rate for the individual product reliability is restricted by the actual burn-in sample size of the product. Failure Rate Determination is based on JEDEC Standard JESD 85. FIT means one failure per billion hours.

FIT rate (failures per billion device hours): 0.150
MTTF = 6,649.6 million hrs
Condition: $\mathrm{V}_{0}=20 \mathrm{~V}, \mathrm{~T}_{\mathrm{o}}=55^{\circ} \mathrm{C}, \mathrm{V}_{\mathrm{s}(\text { DriverIC })}=28 \mathrm{~V}, \mathrm{~V}_{\mathrm{s}(\mathrm{MOSFET})}=25 \mathrm{~V}$ and $\mathrm{T}_{\mathrm{s}}=150^{\circ} \mathrm{C}$
Sample Size: MOSFET $=6,153$, Driver IC $=3,874$
The failure rate $(\lambda)$ is calculated as follows:
$\lambda=\chi^{2}[C L,(2 f+2)] / 2 \times[1 /(S S \times t \times A F)]$; [equation 1$] \quad$ where $\quad C L=\%$ of confidence level
$\mathrm{f}=$ number of failure
SS = sample size $\mathrm{t}=$ stress time

Looking up the $\chi^{2} / 2$ table for zero failure (burn-in) with $60 \%$ confidence, the value of $\chi^{2}[C L,(2 f+2)] / 2$ is 0.92 .
The Acceleration Factor (AF) is calculated from the following formula (both temperature and voltage acceleration factors are used in the final acceleration factor calculation) :
$A F=A F_{T} \times A F_{V}=\exp \left[\left(E_{a} / k\right) \times\left(1 / T_{0}-1 / T_{S}\right)\right] \times \exp [\beta(\mathrm{Vs}-\mathrm{Vo})]$ where $\quad E_{a}=$ activation energy
k = Boltzmann constant
$\mathrm{T}_{\mathrm{o}}=$ operating $\mathrm{T}_{\mathrm{J}}$
$\mathrm{T}_{\mathrm{s}}=$ stress $\mathrm{T}_{\mathrm{J}}$
$\mathrm{V}_{\mathrm{s}}=$ stress voltage
$\mathrm{V}_{\mathrm{o}}=$ operating voltage
$\beta=$ voltage acceleration coefficient
Assuming typical operating environment, $\mathrm{V}_{\mathrm{o}}=20 \mathrm{~V}, \mathrm{~T}_{\mathrm{o}}=55^{\circ} \mathrm{C}, \mathrm{E}_{\mathrm{a}}=0.7 \mathrm{eV}, \mathrm{V}_{\mathrm{s}(\text { DriverIC })}=28 \mathrm{~V}, \mathrm{~V}_{\mathrm{s}(\mathrm{MOSFET})}=25 \mathrm{~V}$, $\mathrm{T}_{\mathrm{s}}=150^{\circ} \mathrm{C}, \beta=0.5$ (silicon defect)
$A F($ DriverIC $)=\exp \left[\left(\frac{0.7}{8.617 E-5}\right) \bullet\left(\frac{1}{273+55}-\frac{1}{273+150}\right)\right] \bullet \exp [0.5 \bullet(28 V-20 V)]$
$A F(M O S F E T)=\exp \left[\left(\frac{0.7}{8.617 E-5}\right) \bullet\left(\frac{1}{273+55}-\frac{1}{273+150}\right)\right] \bullet \exp [0.5 \bullet(25 V-20 V)]$

Substituting the values in equation 1 , we have $\lambda=2 \bullet \lambda(M O S F E T)+\lambda($ DriverIC $)=$
$0.92 \bullet \frac{2}{\text { Sample Size } \bullet \text { Stress Duration } \bullet A F(M O S F E T)}+\frac{1}{\text { sample Size } \bullet \text { Stress Duration } \bullet A F(\text { DriverIC })} h r^{-1}$
$\lambda=0.15010^{-9} \mathrm{hr}^{-1}$ or $0.150 \mathrm{FIT} ; \mathrm{MTTF}=(1 / \lambda)=6,649.6$ million hrs $=759,089$ years
The calculation shows failure rate is 0.150 FIT, MTTF is $6,649.6$ million hours under typical operating conditions.
The qualification test results confirm that AOZ5311NQI passes AOS quality and reliability requirements for product manufacturing release.

| Revision | Release Date | Comments |
| :---: | :--- | :--- |
| 1.0 | April 1, 2019 | Initial Release |
| 1.1 | May 1, 2019 | Updated FIT to include voltage acceleration factor |

